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**VE320 – Summer 2021**

**Introduction to Semiconductor Devices**

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**Chapter 12 Bipolar Junction Transistor**



# Outline

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12.1 Review and example

12.2 Bipolar Junction transistor

12.3 Early Effect

12.4 Summary

12.5 Quantitative analysis of BJT gain

# Outline

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## 12.1 Review and example

## 12.2 Bipolar Junction transistor

## 12.3 Early Effect

## 12.4 Summary

## 12.5 Quantitative analysis of BJT gain

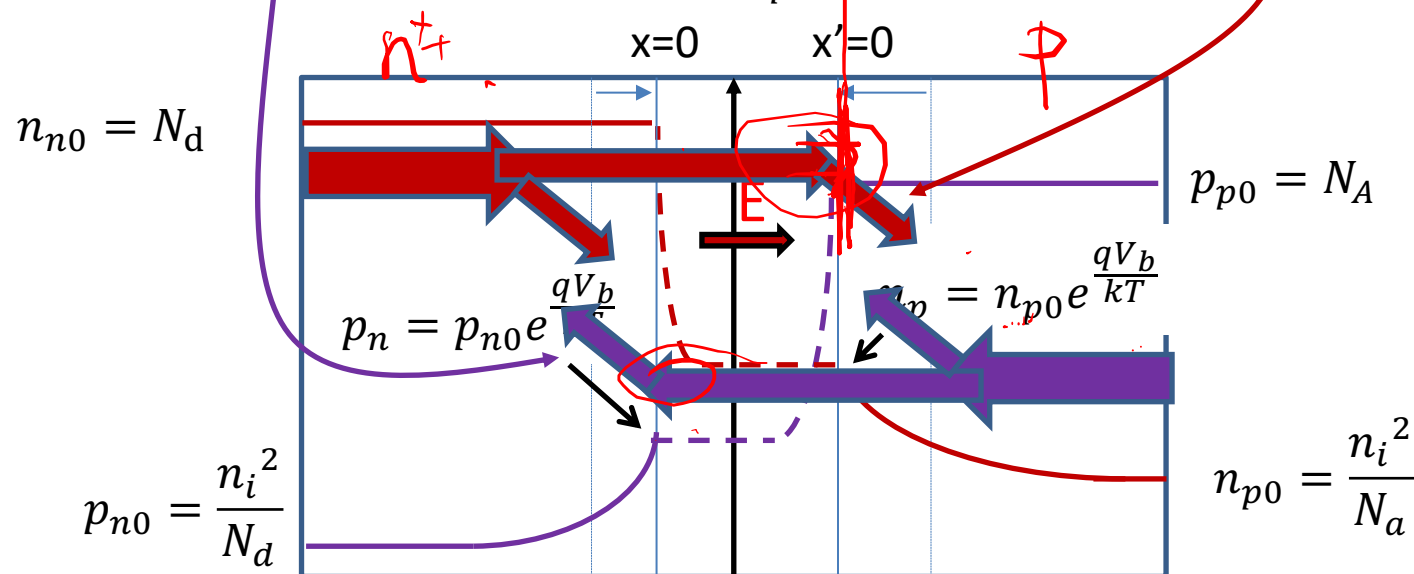
# 12.1 Previously: pn Junction Current

- charge carrier transport: forward bias: current ratio

$$J_n = -qD_n \frac{dn_p}{dx} = -\frac{qD_n n_{p0}}{L_n} (e^{\frac{qV_b}{kT}} - 1) e^{-x/L_n}$$

$$J_p = -qD_p \frac{dp_n}{dx} = -\frac{qD_p p_{n0}}{L_p} (e^{\frac{qV_b}{kT}} - 1) e^{x/L_p}$$

$$\frac{J_n}{J_p} = \frac{D_n N_d / L_n}{D_p N_a / L_p}$$



Assumption: No recombination-generation in depletion region.

## 12.1 Example: pn Junction Current

Finding  $L_n$ ,  $\tau_n$  in **p-type** region because electrons are minority carriers.

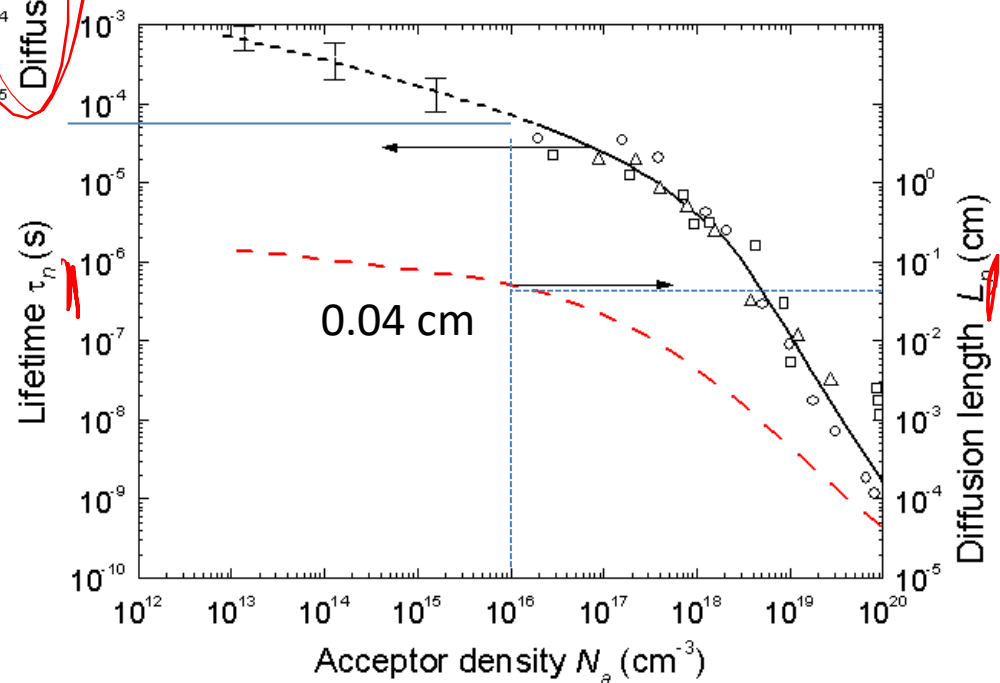
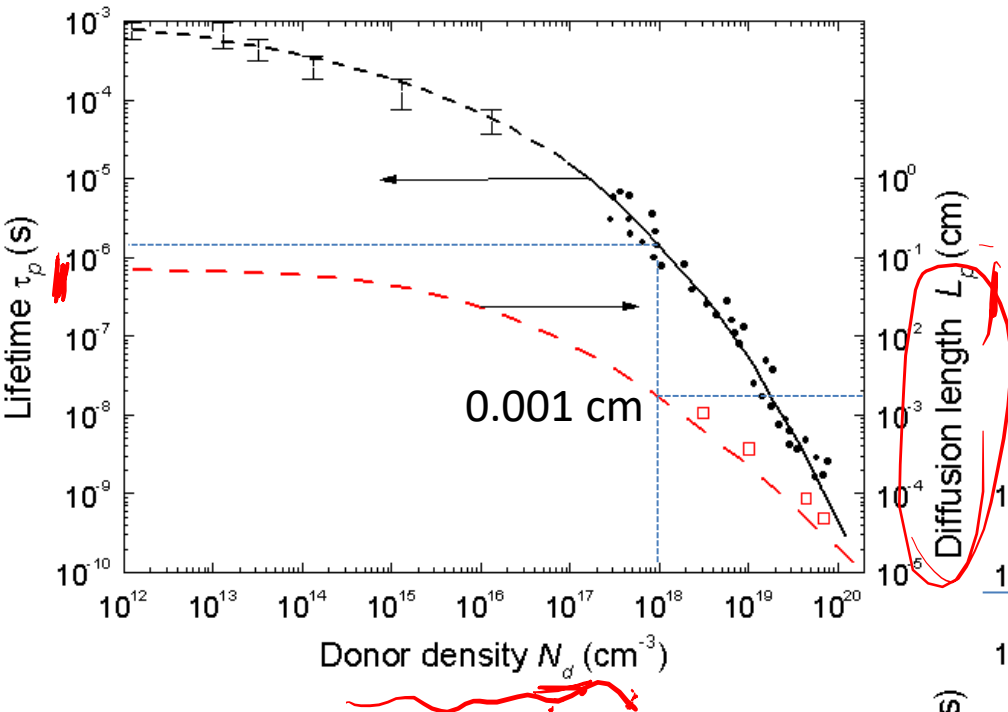
$$\text{For } N_a = 10^{16} \text{ cm}^{-3} \quad L_n = 0.04 \text{ cm} \quad \tau_n = 5 \times 10^{-5} \text{ s}$$

Finding  $L_p$ ,  $\tau_p$  in **n-type** region because holes are minority carriers.

$$\text{For } N_d = 10^{18} \text{ cm}^{-3} \quad L_p = 0.0015 \text{ cm} \quad \tau_p = 1.5 \times 10^{-6} \text{ s}$$

$$\frac{J_n}{J_p} = \frac{D_n N_d / L_n}{D_p N_a / L_p} = \frac{L_n / \tau_n N_d}{L_p / \tau_p N_a} \approx \frac{\frac{4 \times 10^{-2}}{5 \times 10^{-5}}}{\frac{1.5 \times 10^{-3}}{1.5 \times 10^{-6}}} \times \frac{10^{18}}{10^{16}} = 80$$

# 12.1 Example: pn Junction Current



<http://www.ioffe.ru/SVA/NSM/Semicond/Si/>

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12.1 Review and example

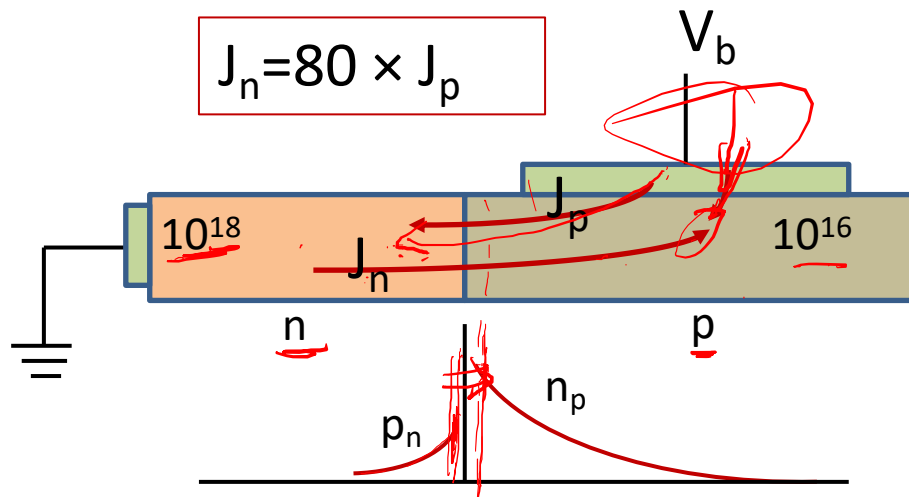
**12.2 Bipolar Junction transistor**

12.3 Early Effect

12.4 Summary

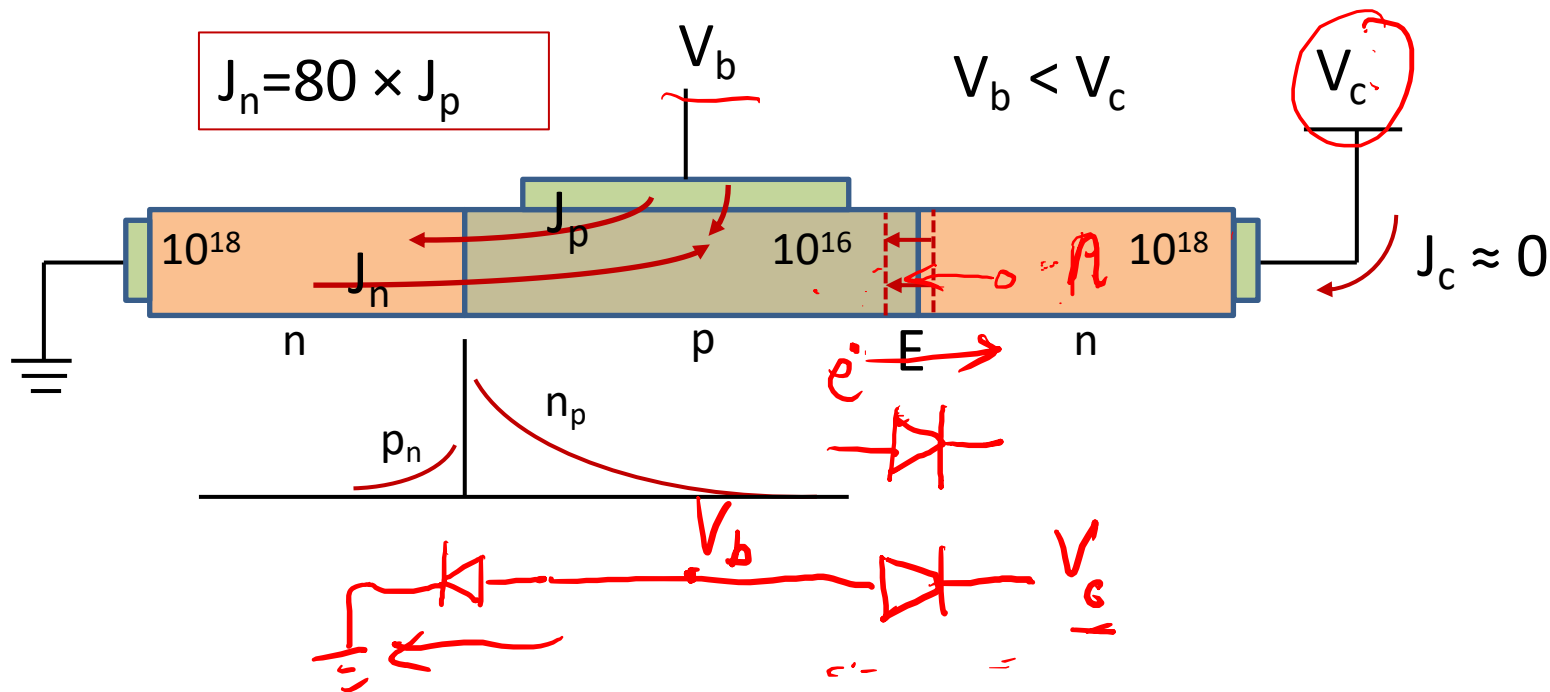
12.5 Quantitative analysis of BJT gain

## 12.2 Bipolar Junction transistor

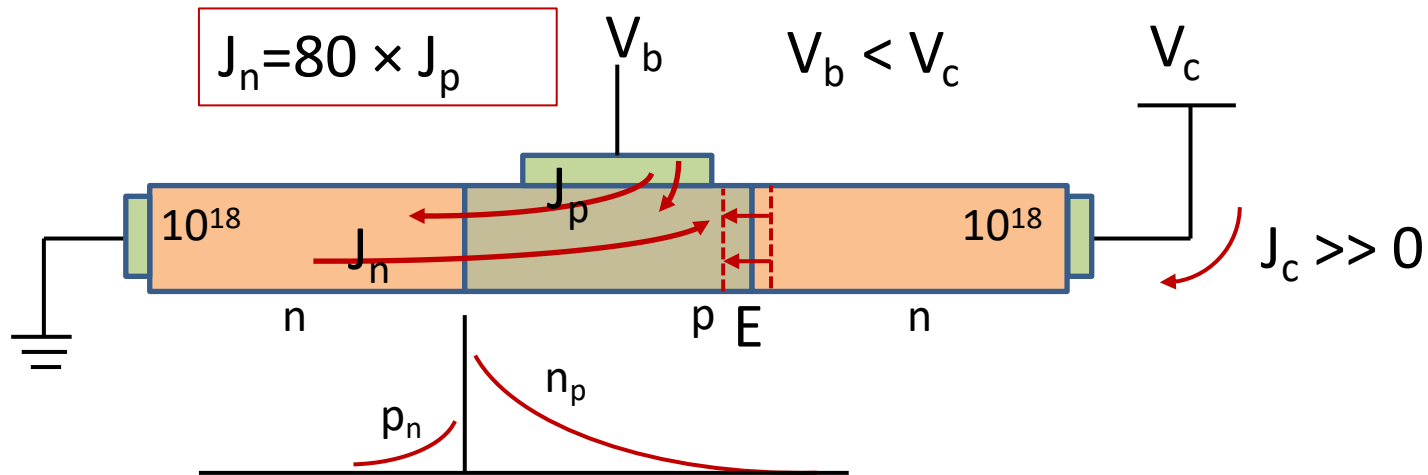




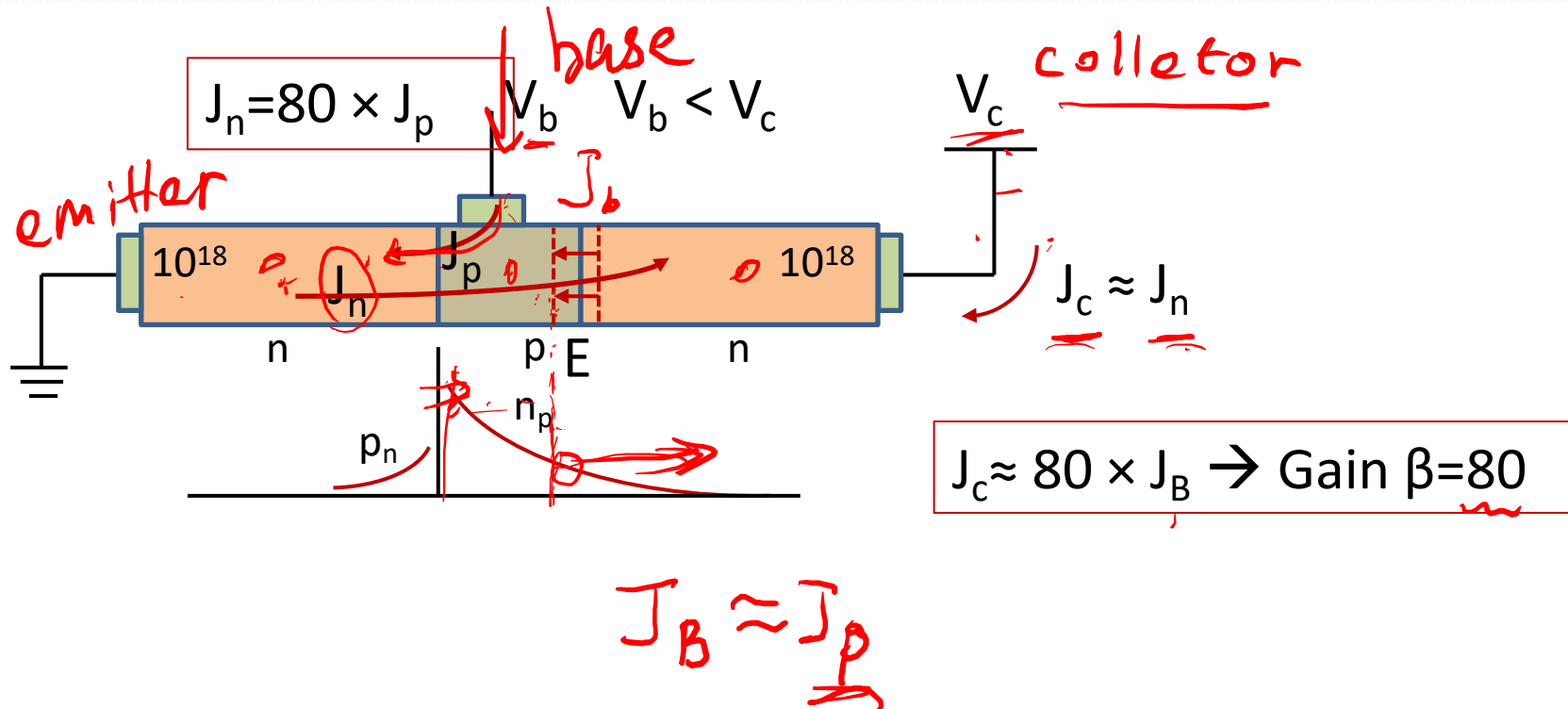
## 12.2 Bipolar Junction transistor



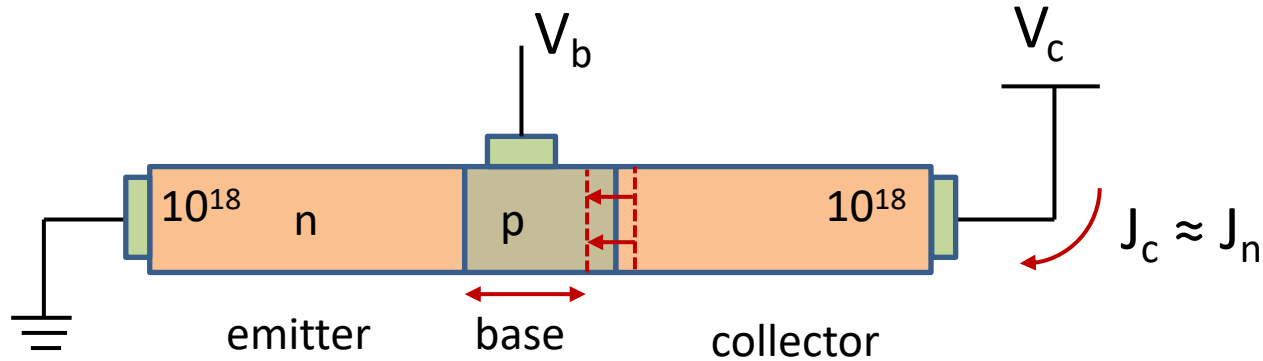
## 12.2 Bipolar Junction transistor



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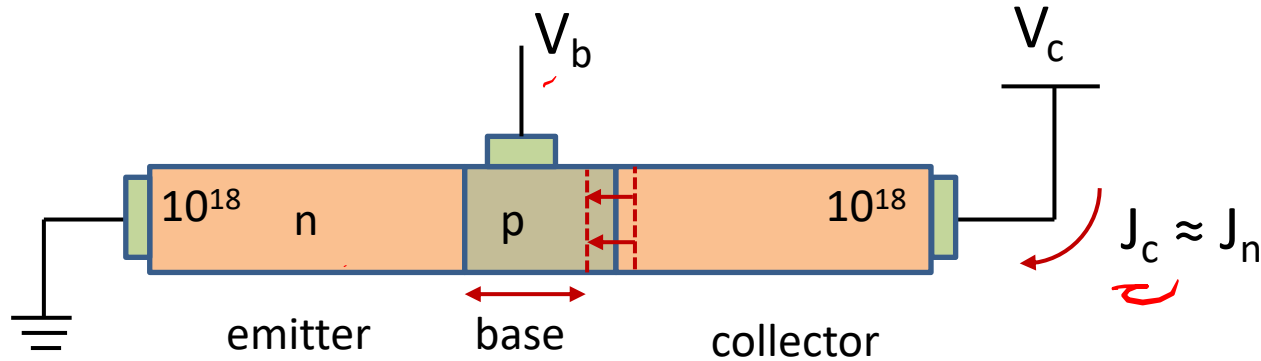


$$J_c \approx 80 \times J_B \rightarrow \text{Gain } \beta = 80$$

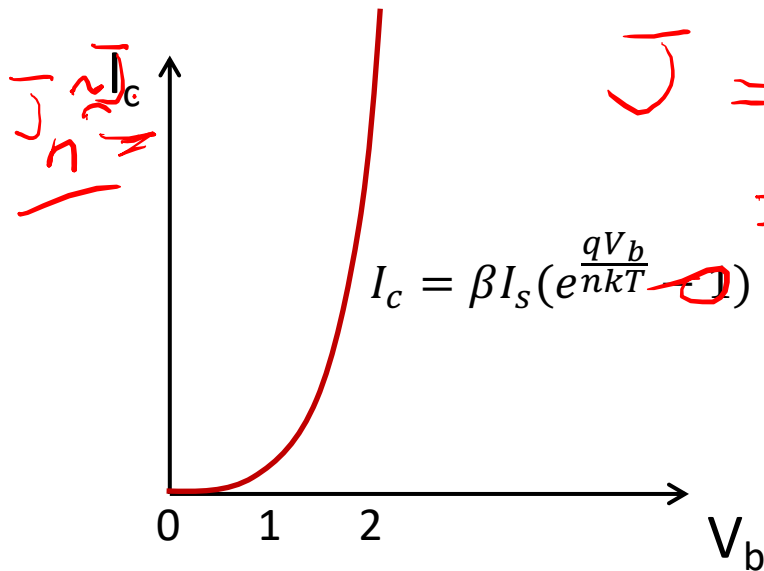
BJT Characteristics:

1. Base width smaller  $\rightarrow$  higher gain
2. Larger emitter-base concentration ratio  $\rightarrow$  higher gain

# 12.2 Bipolar Junction transistor: I-V

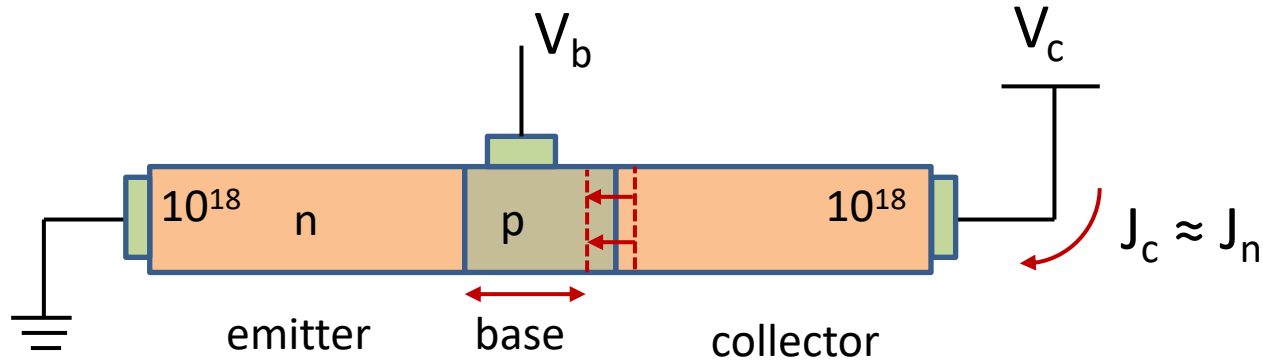


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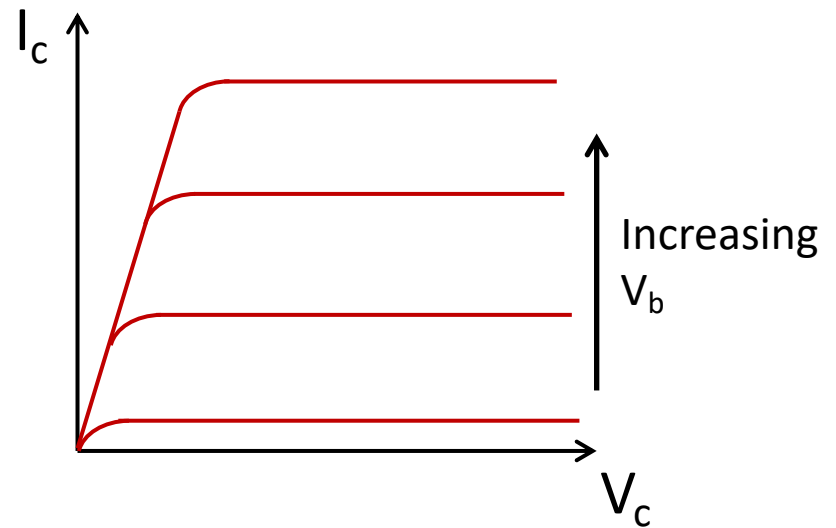
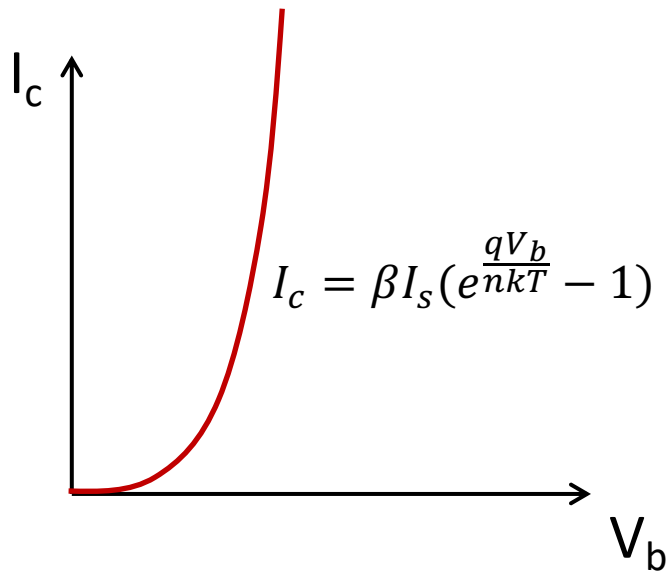


$$\begin{aligned}
 J &= J_s \left( e^{\frac{qV_b}{kT}} + 1 \right) \\
 &= \left( \frac{D_n n_{p0}}{L_n} + \frac{D_p p_{n0}}{L_p} \right) e^{\frac{qV_b}{kT}} \\
 &\approx \underbrace{\frac{D_n n_{p0}}{L_n}}_{J_n} e^{\frac{qV_b}{kT}} + \underbrace{\frac{D_p p_{n0}}{L_p}}_{J_p} e^{\frac{qV_b}{kT}}
 \end{aligned}$$

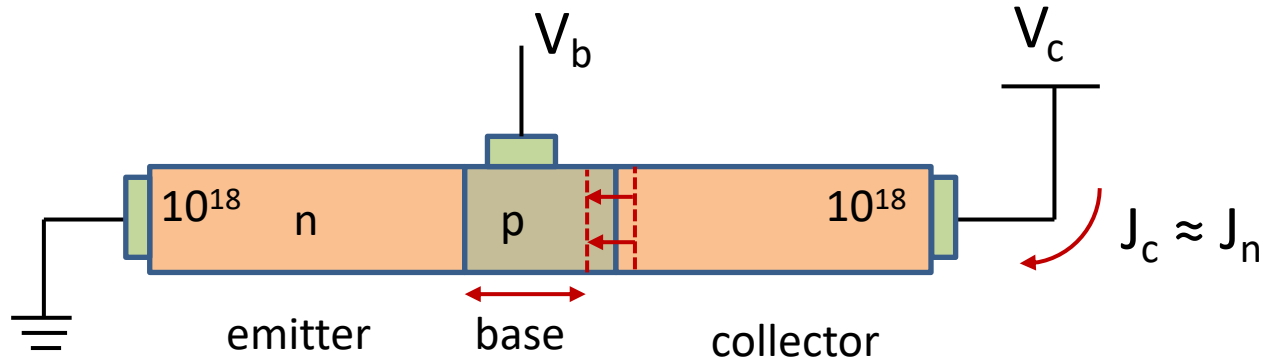
## 12.2 Bipolar Junction transistor: I-V



$$J_c \approx 80 \times J_B \rightarrow \text{Gain } \beta = 80$$

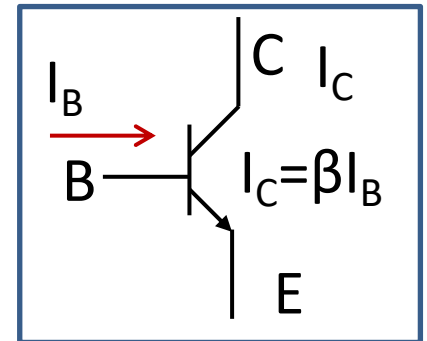


## 12.2 Bipolar Junction transistor: I-V

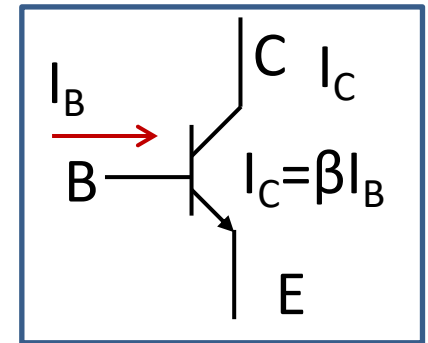
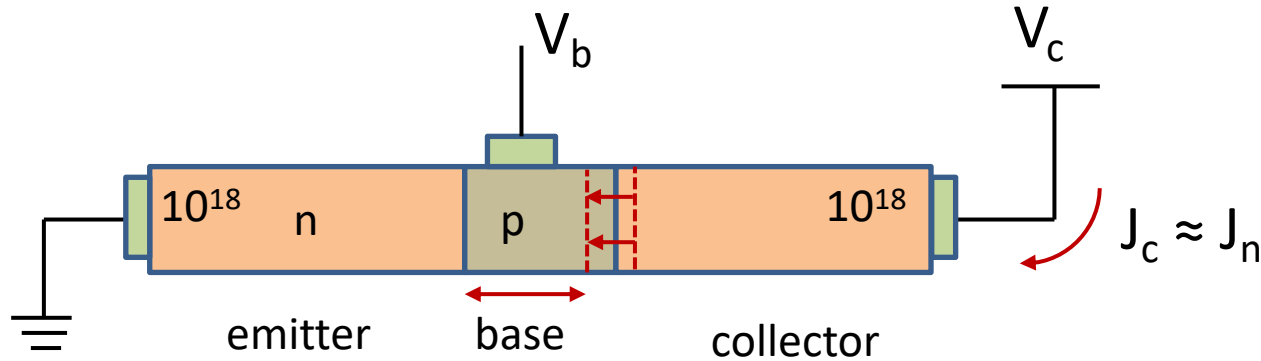


$$J_c \approx 80 \times J_B \rightarrow \text{Gain } \beta = 80$$

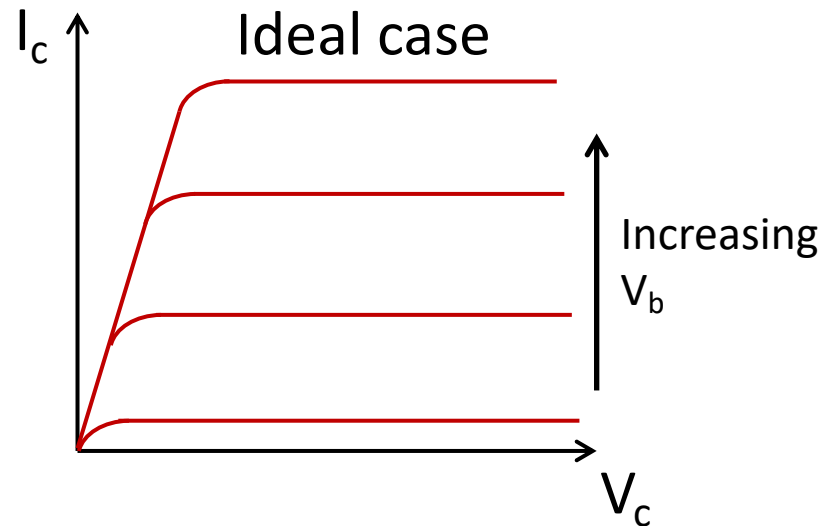
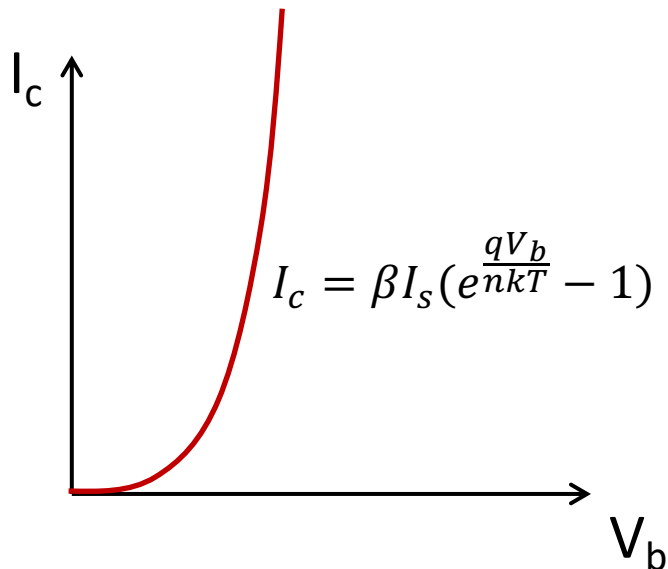
Basic facts:



# 12.2 Bipolar Junction transistor: I-V



$$J_c \approx 80 \times J_B \rightarrow \text{Gain } \beta = 80$$





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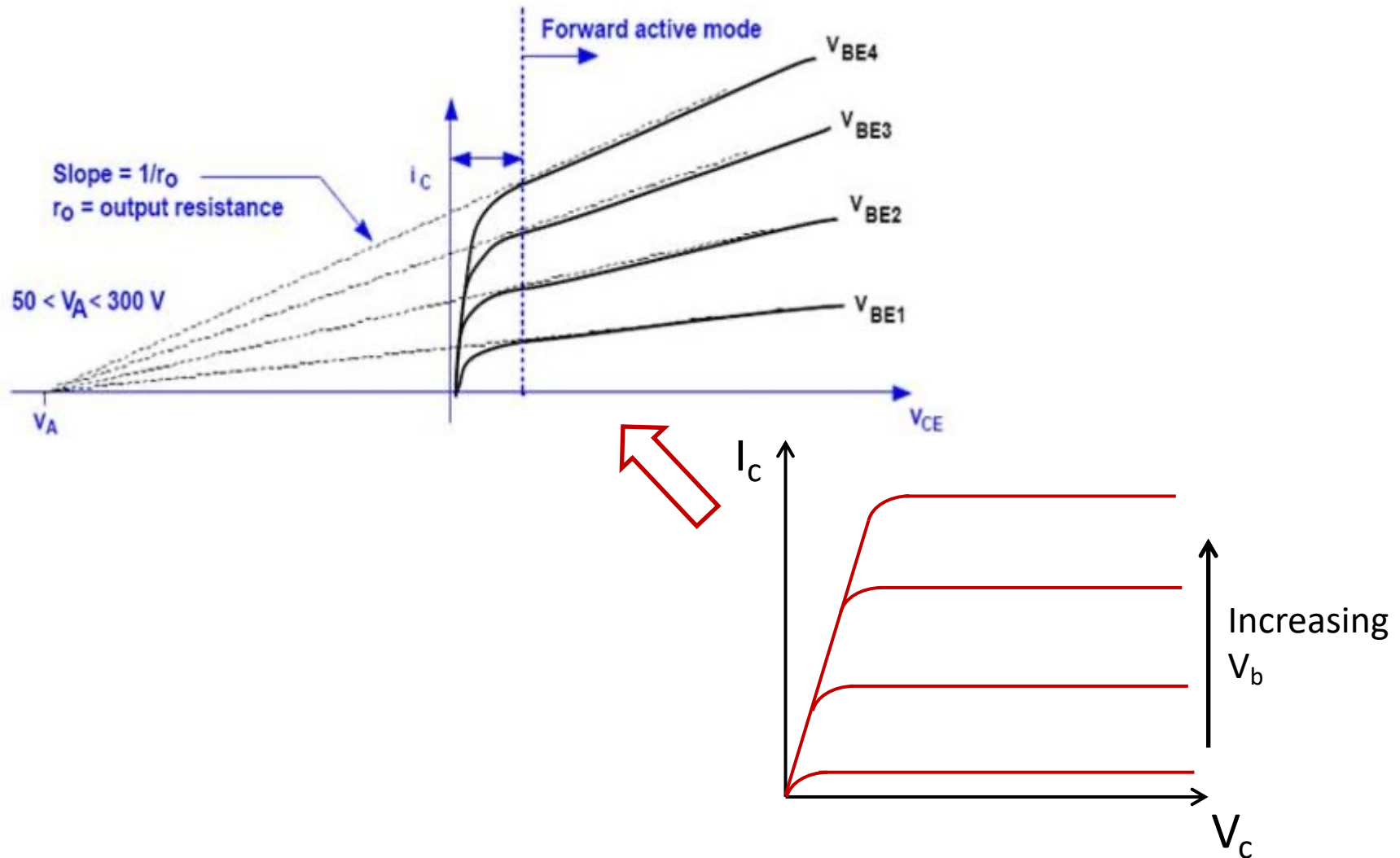
12.2 Bipolar Junction transistor

**12.3 Early Effect**

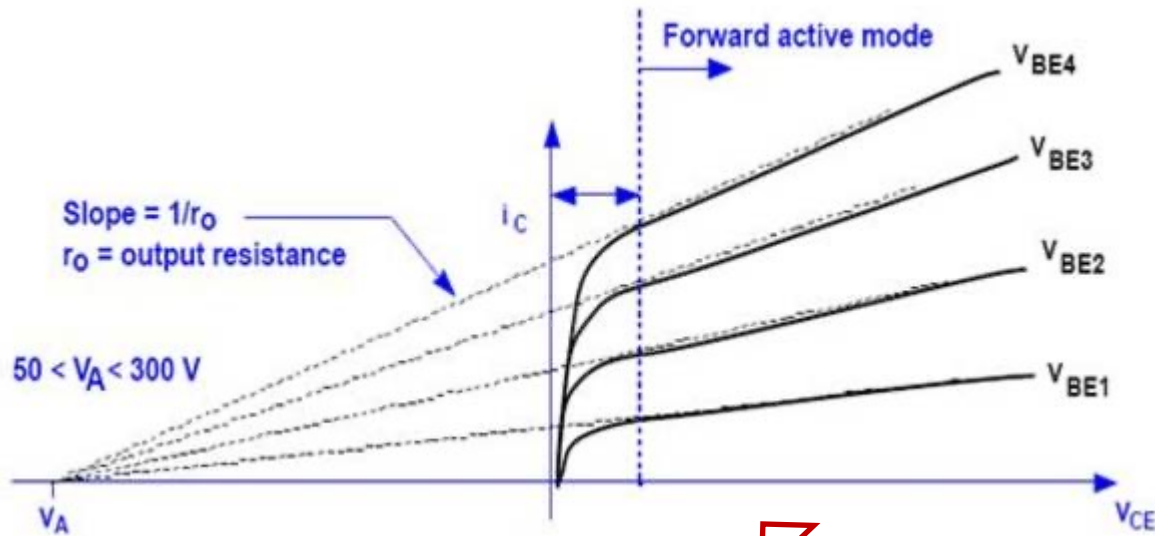
12.4 Summary

12.5 Quantitative analysis of BJT gain

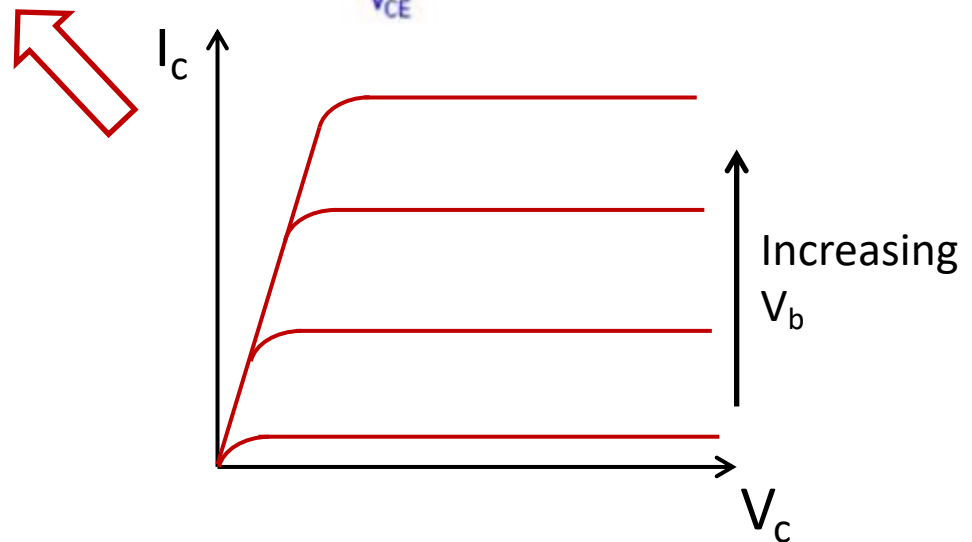
## 12.3 Early Effect



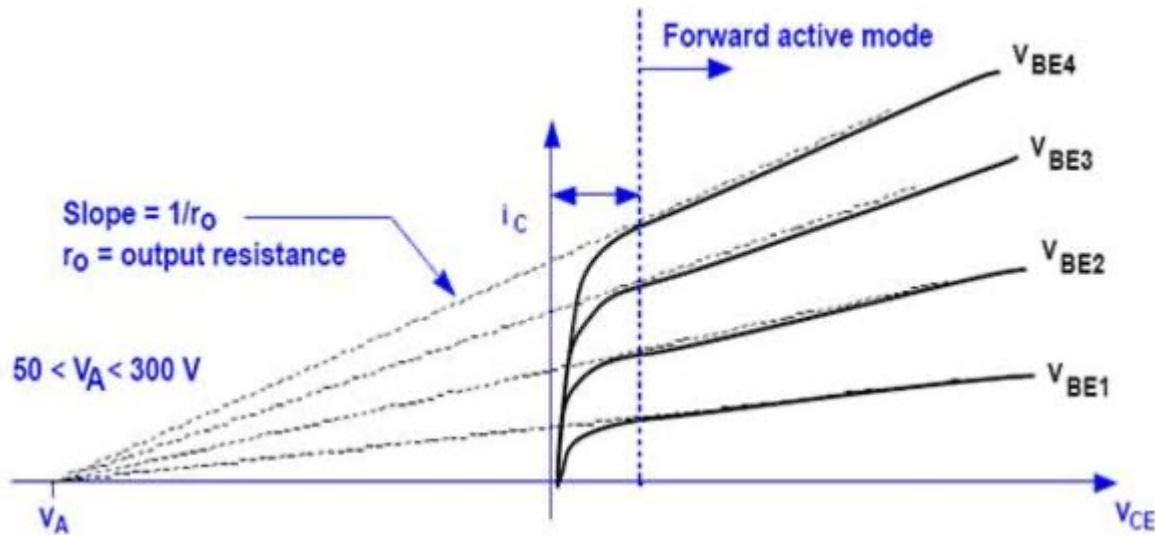
## 12.3 Early Effect



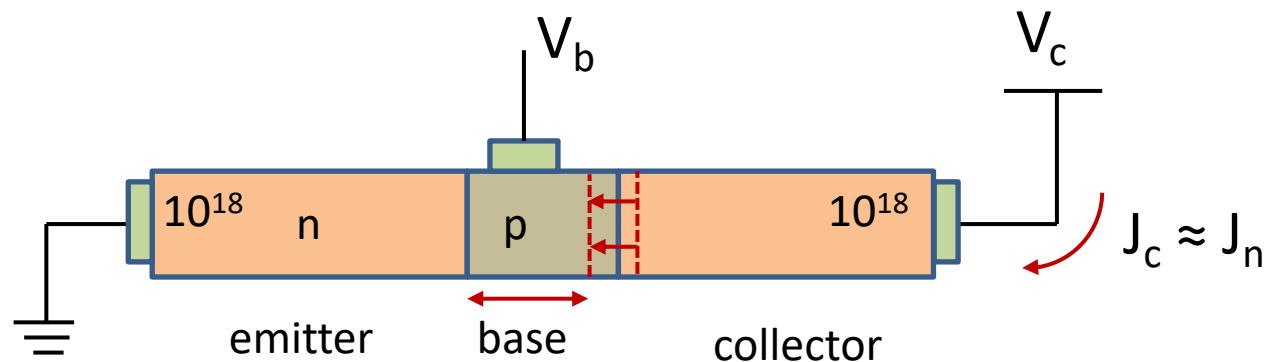
James M. Early



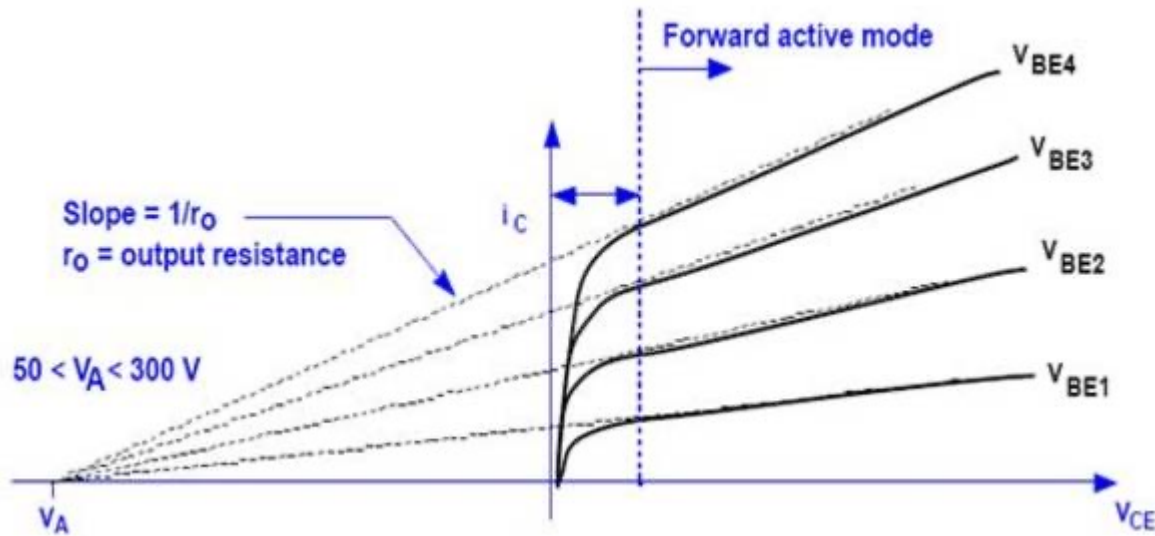
## 12.3 Early Effect



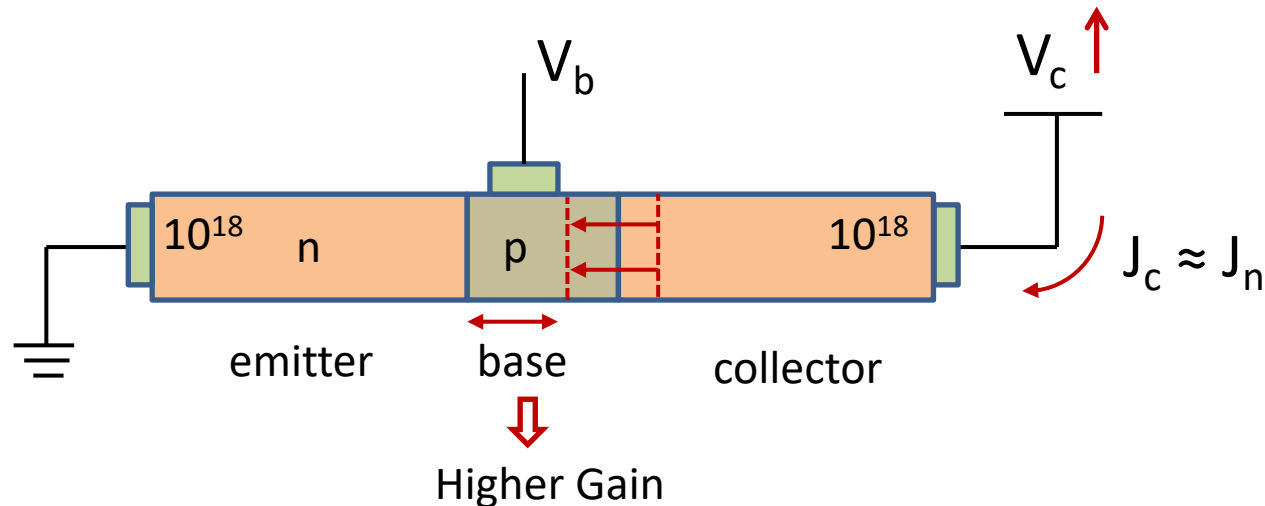
James M. Early



## 12.3 Early Effect



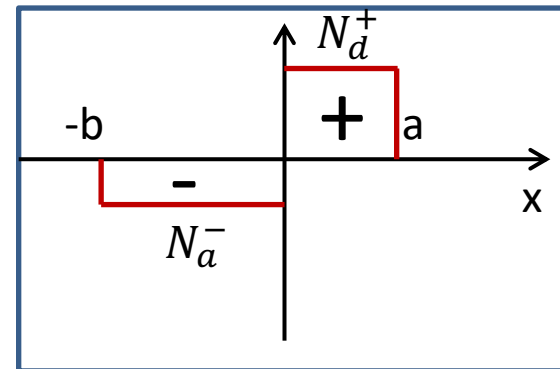
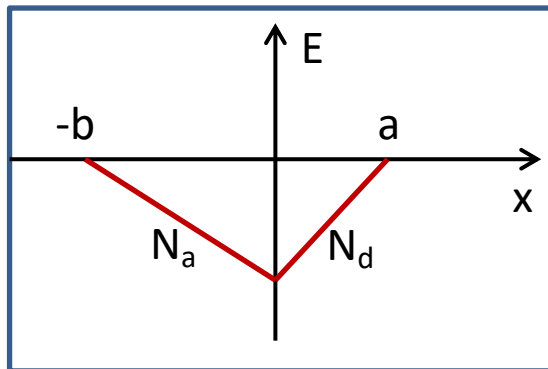
James M. Early



# Previously...

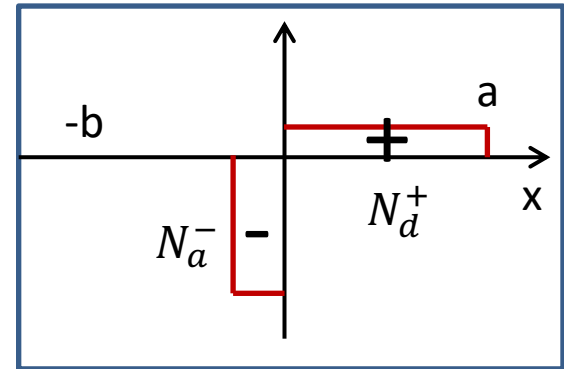
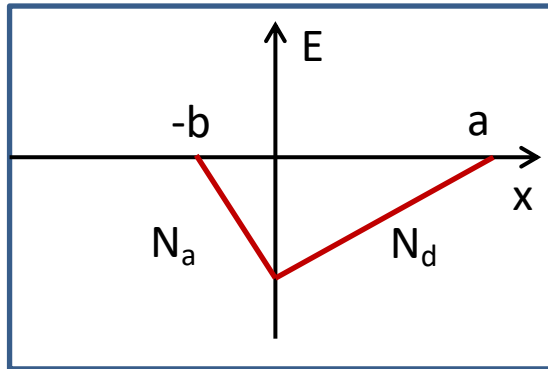
$$a = \sqrt{\frac{2\varepsilon(V_{bi}-V_R)}{q} \frac{N_a}{N_d} \frac{1}{N_a + N_d}}$$

$$N_A^- b = N_D^+ a \Rightarrow b = \sqrt{\frac{2\varepsilon(V_{bi}-V_R)}{q} \frac{N_d}{N_a} \frac{1}{N_a + N_d}}$$



# Previously...

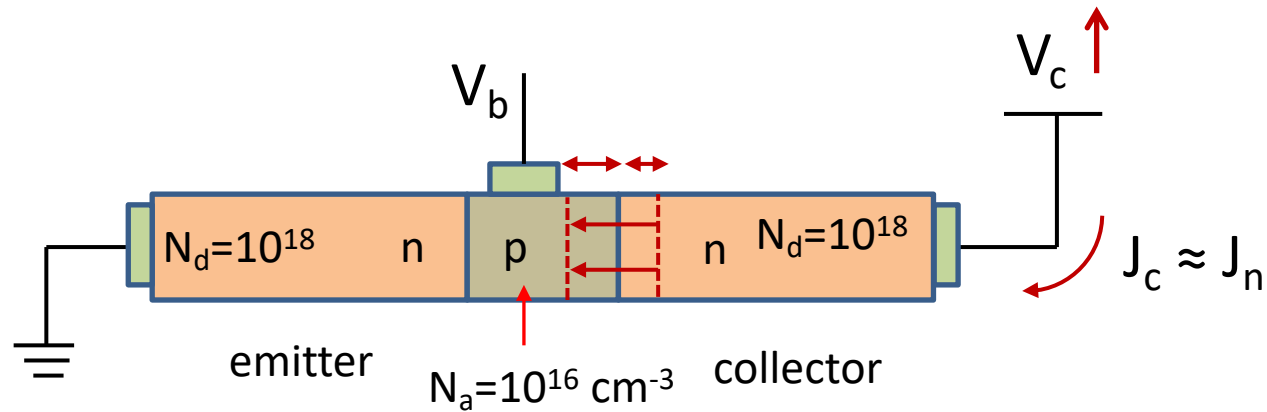
Depletion region width  $W = a + b$



## 12.3 Early Effect



James M. Early

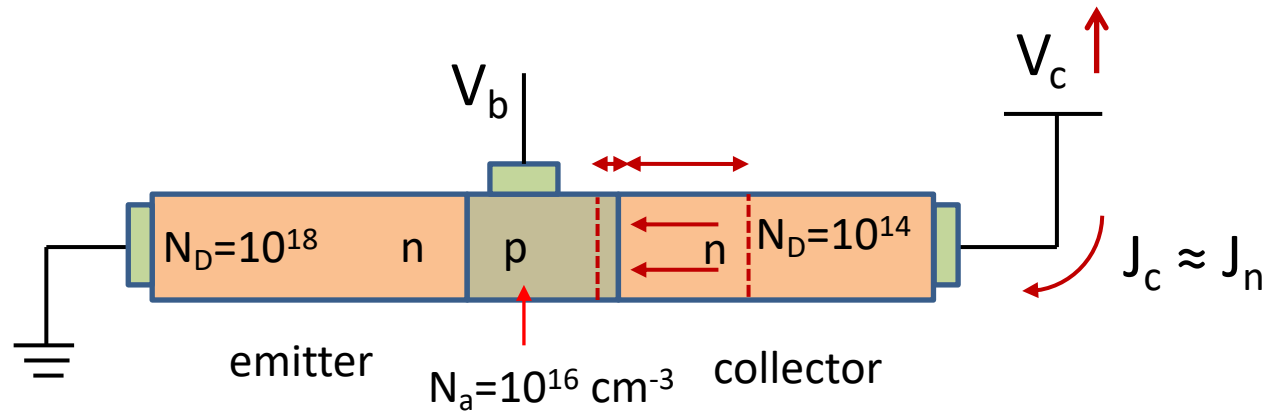




## 12.3 Early Effect



[James M. Early](#)



## 12.3 Early Effect

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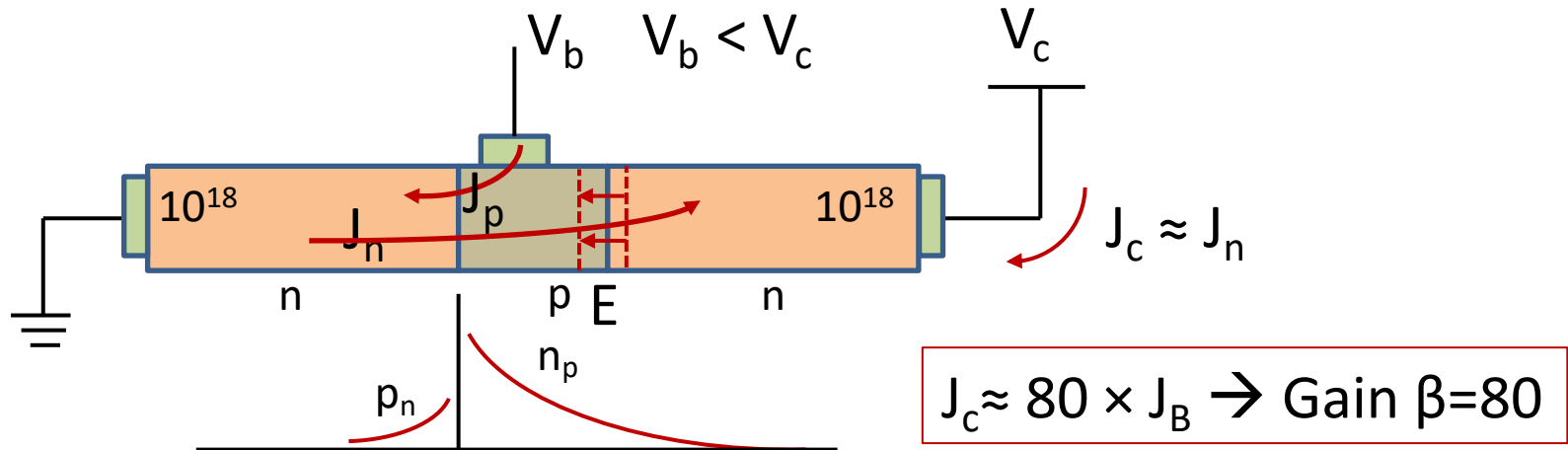
12.2 Bipolar Junction transistor

12.3 Early Effect

**12.4 Summary**

12.5 Quantitative analysis of BJT gain

## 12.4 Summary



1. highest doping concentration is limited by solubility ( $<10^{20}$ )
2. Lowest doping concentration is limited by  $n_i$  and fabrication process

Basic facts:

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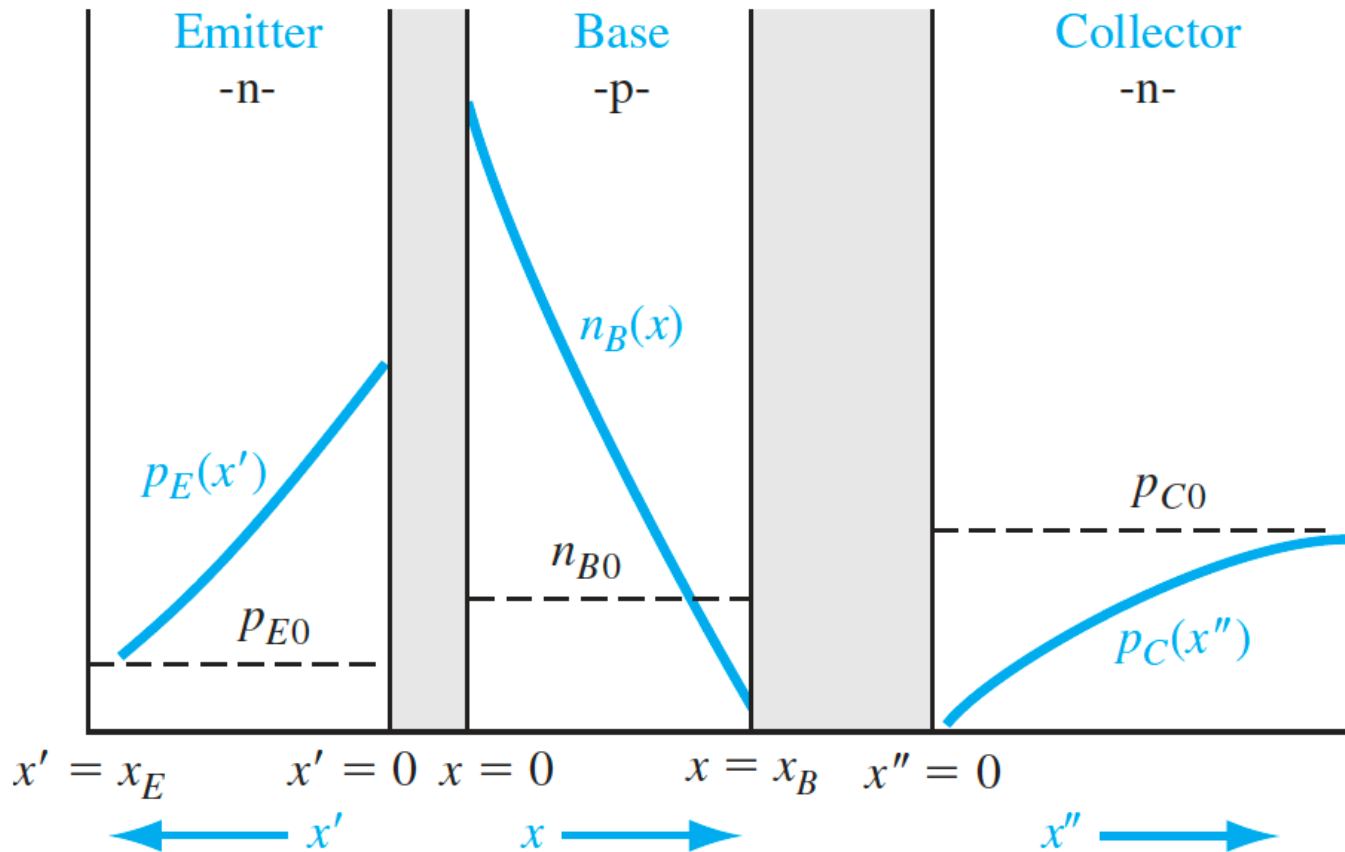
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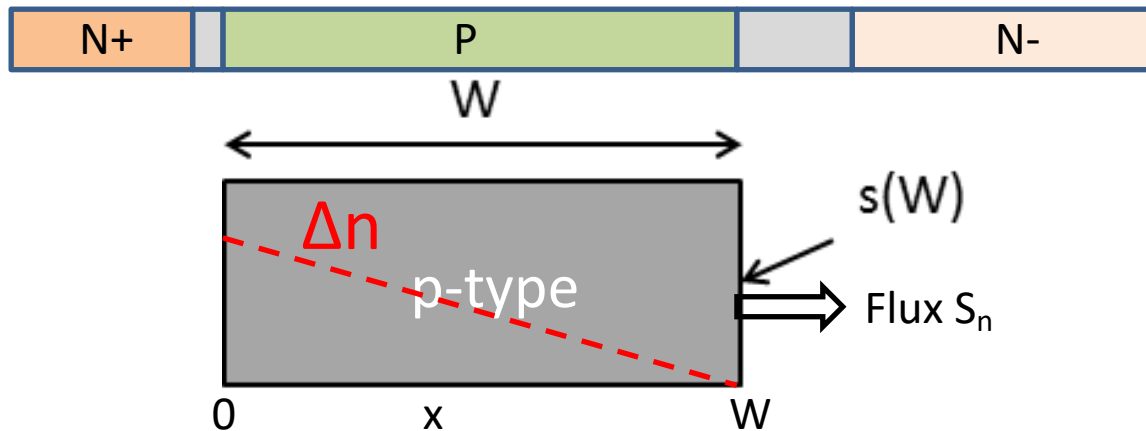
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**12.5 Quantitative analysis of BJT gain**

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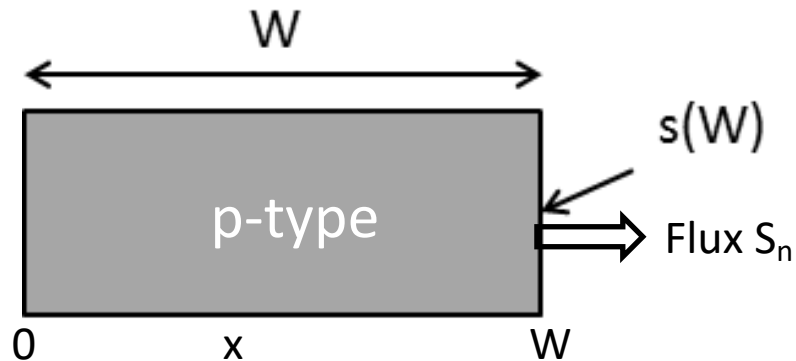


$$N_a = 10^{17} \text{ cm}^{-3}, D_n = 10 \text{ cm}^2/\text{s}, \tau_n = 10^{-7} \text{ s}, \text{SRV } s(x=W) = \infty$$
$$\Delta n(x=0) = 10^{14} \text{ cm}^{-3}$$

Find the electron flux  $S_n$  at  $x=0$  and  $W$ , if

- 1)  $W=20\mu\text{m}$
- 2)  $W=2\mu\text{m}$

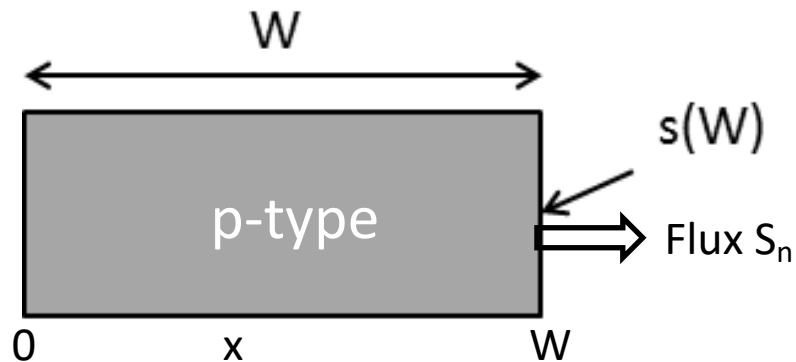
## 12.5 Quantitative analysis of BJT gain



$$0 = D_n \frac{\partial^2 \Delta n}{\partial x^2} - \frac{\Delta n}{\tau}$$

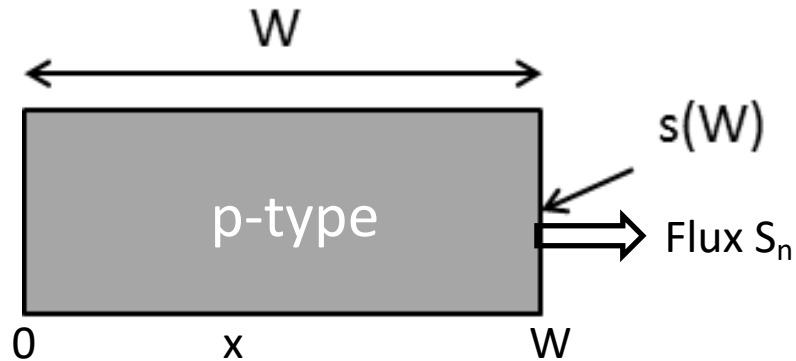


## 12.5 Quantitative analysis of BJT gain



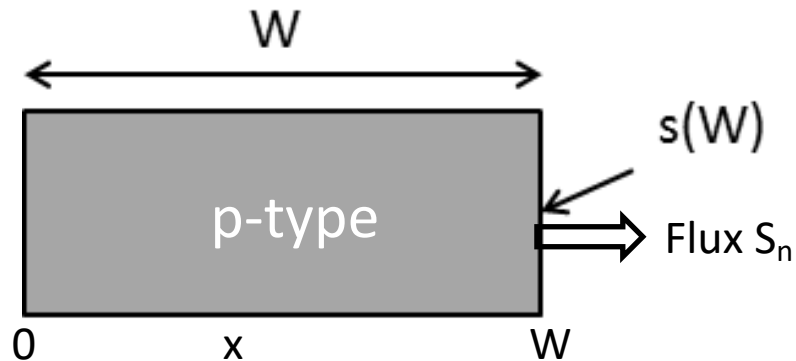
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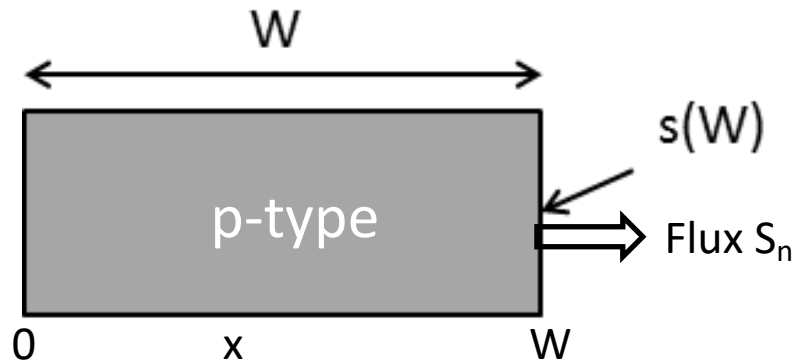
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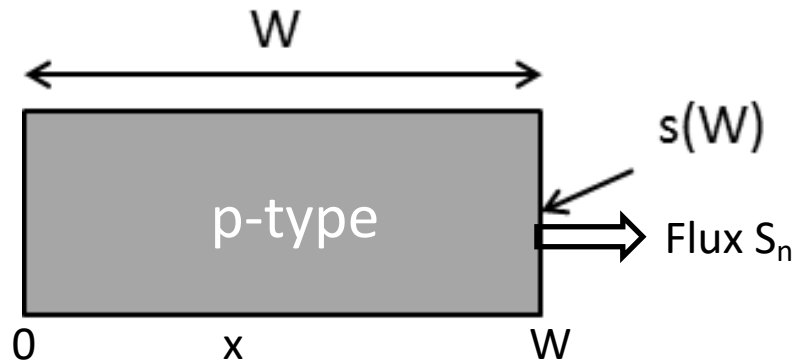
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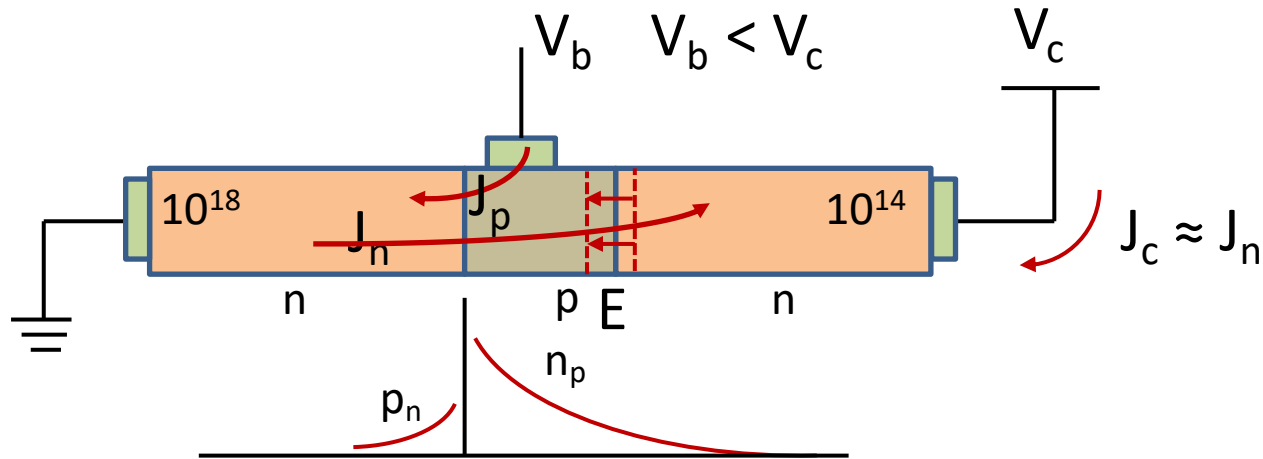


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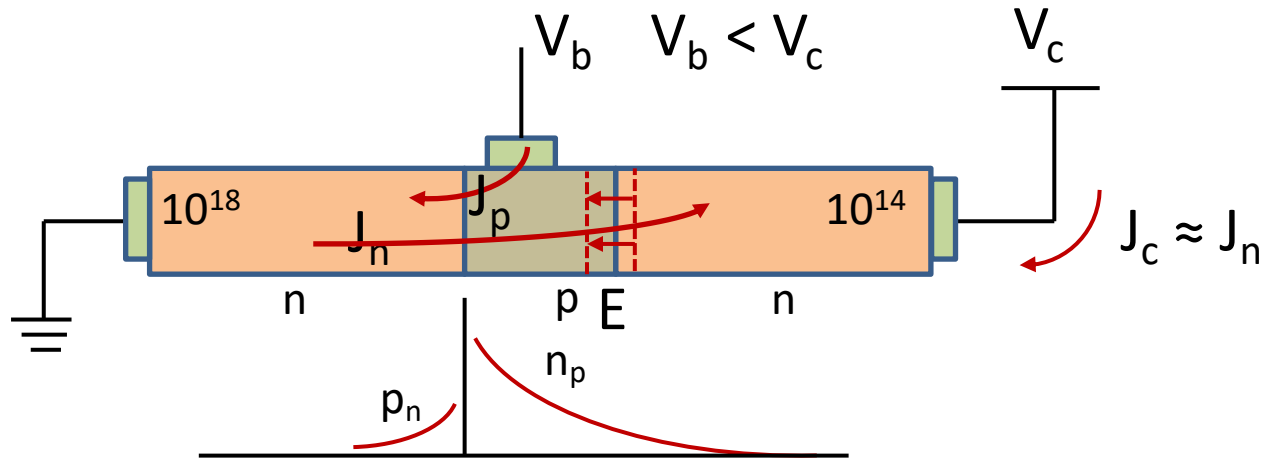
## 12.5 Quantitative analysis of BJT gain



Electron flux from emitter to base:  $S_n(0)$

Electron flux from base to collector:  $S_n(W_b)$

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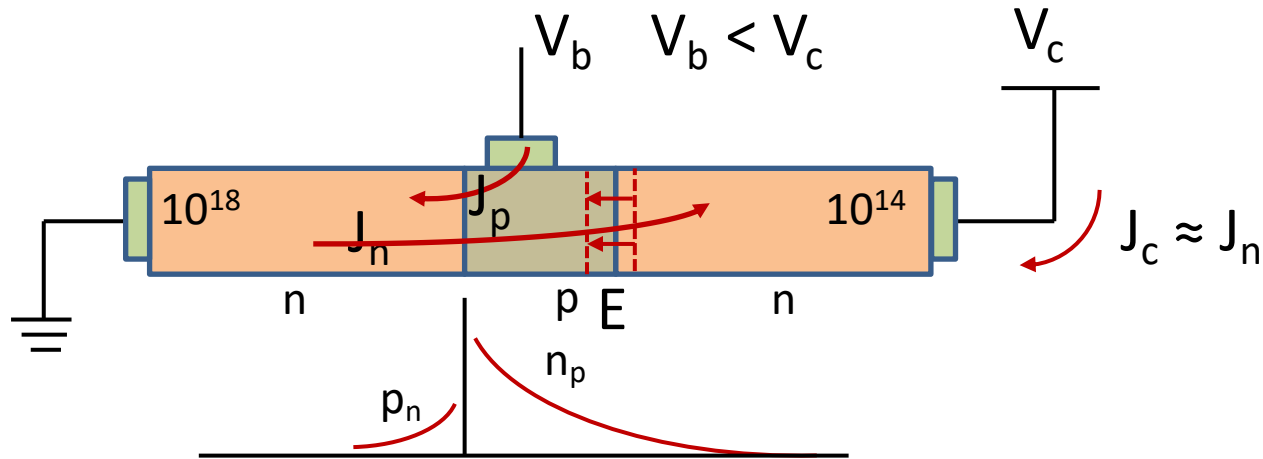


Electron flux from emitter to base:  $S_n(0)$

Electron flux from base to collector:  $S_n(W_b)$

Hole flux from base to emitter:  $S_p$

## 12.5 Quantitative analysis of BJT gain



Electron flux from emitter to base:  $S_n(0)$

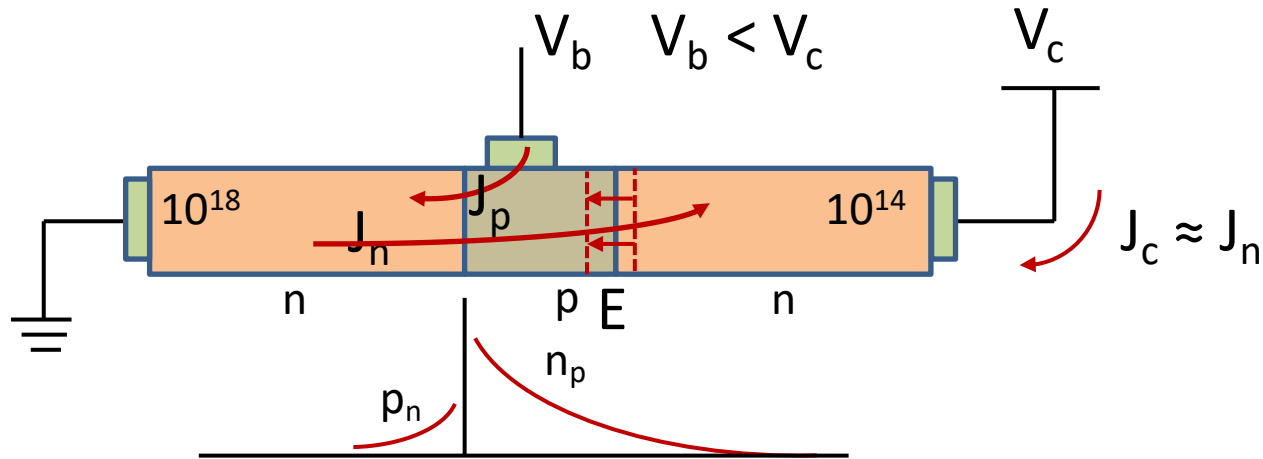
Electron flux from base to collector:  $S_n(W_b)$

Hole flux from base to emitter:  $S_p$

Base electrode flux:  $S_p + S_n(0) - S_n(W_b)$



## 12.5 Quantitative analysis of BJT gain



Electron flux from emitter to base:  $S_n(0)$

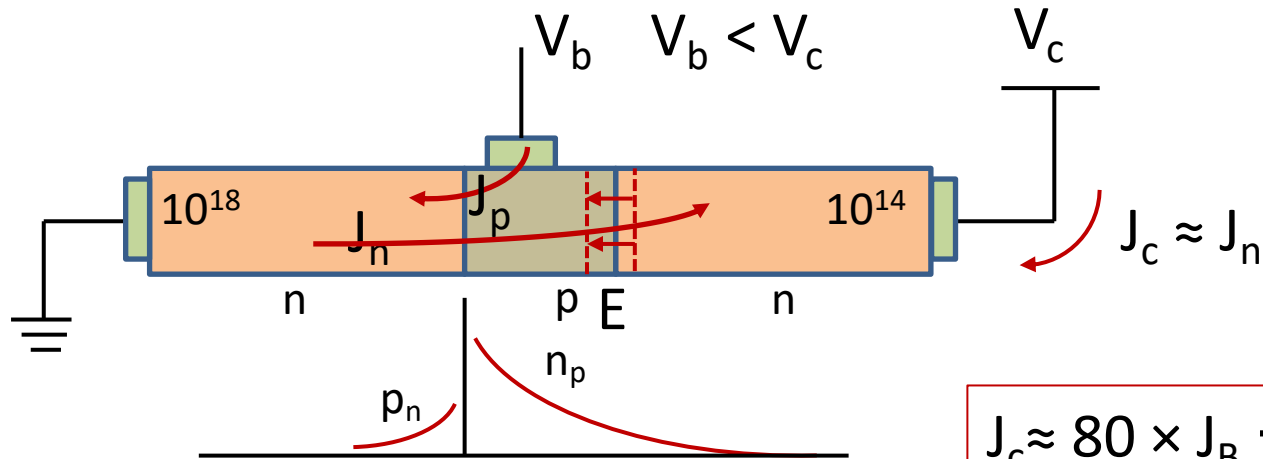
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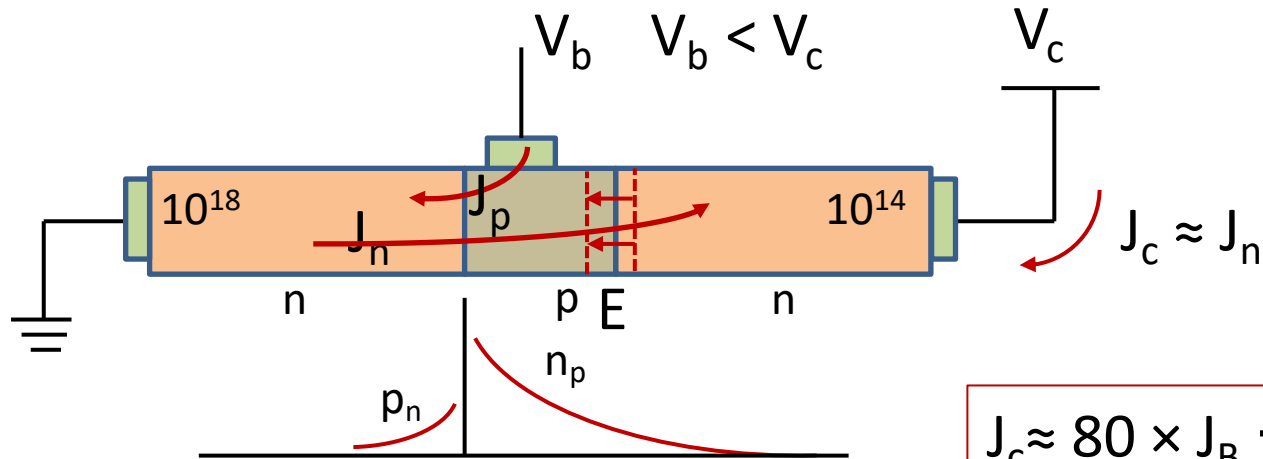
Base electrode flux:  $S_p + S_n(0) - S_n(W_b)$

Gain  $\beta$  = collector flux / base electrode flux =  $S_n(W_b) / (S_p + S_n(0) - S_n(W_b))$

## 12.5 Quantitative analysis of BJT gain



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$$J_c \approx 80 \times J_B \rightarrow \text{Gain } \beta = 80$$

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